



MEMS mirror for miniaturized Fourier transform spectrometer

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Business from technology

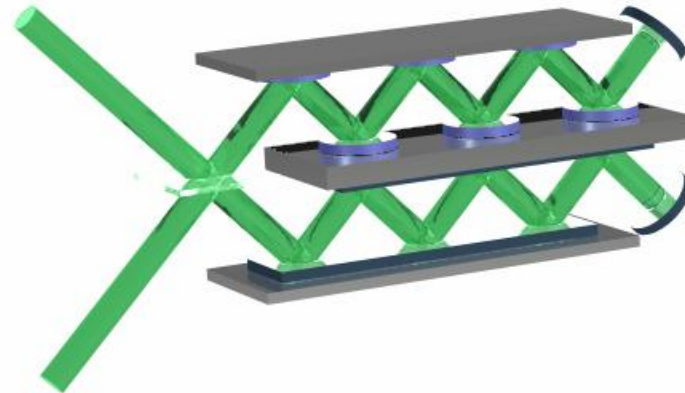
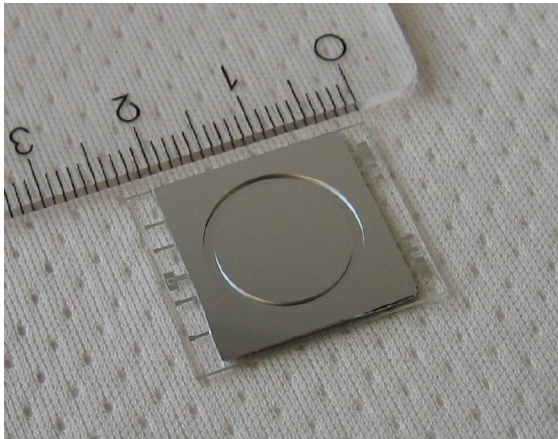
Outline

Large diameter micro-electro-mechanical (MEMS) mirror component

- Design
- Performance

Possible applications

- Miniaturized interferometer platforms



VTT Technical Research Centre of Finland

VTT Technical Research Centre of Finland is a government owned research agency, which will be privatized in 2009.

- 2780 employees, of which ~ 60 people are working in *Optical Instruments Knowledge Centre*.

VTT has modern cleanrooms (ISO 4 ... ISO 7) with state-of-the-art equipment for fabrication of MEMS, CMOS and thin film devices.

- E.g. The core of the *Micronova* building is the 2 600 m² cleanroom.

VTT possesses all parts of the micro-nano innovation chain, from basic research and applied research to prototype development, and small scale manufacturing. Our services are tailored to the customers' needs.

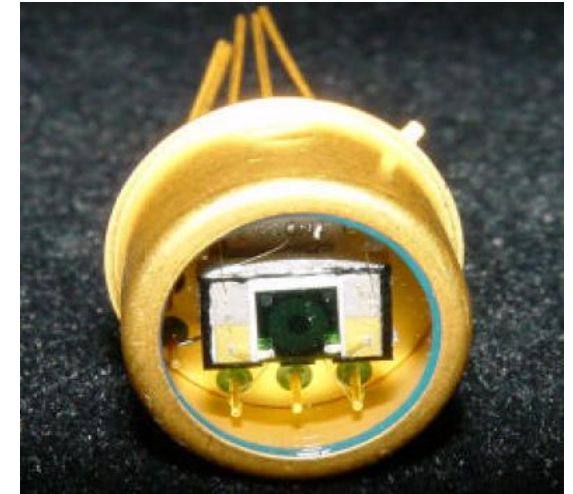
- Research
- Confidential contract research
- Material and device characterization

Optical sensors and space instruments / Optical instruments centre



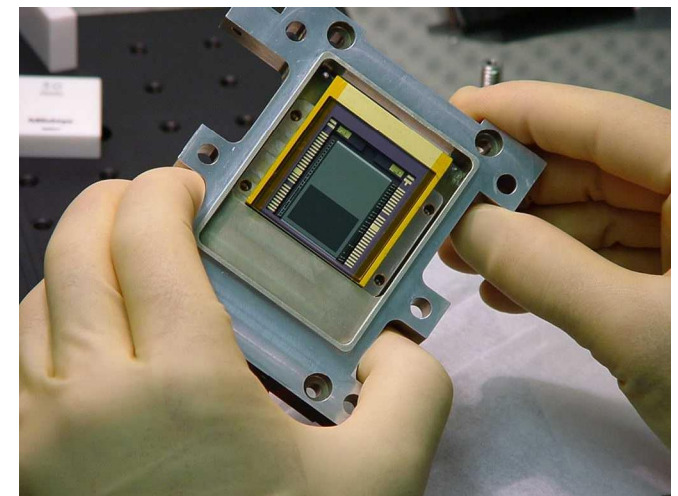
A high-resolution remote sensing camera featuring a novel prism structure with several CCDs creating an image mosaic of 10200 x 1600 pixels. The image is taken from the Barcelona area.

MOEMS spectrometer in a TO-8 can including a MEMS Fabry-Perot interferometer (MFPI), a detector and a cooler.

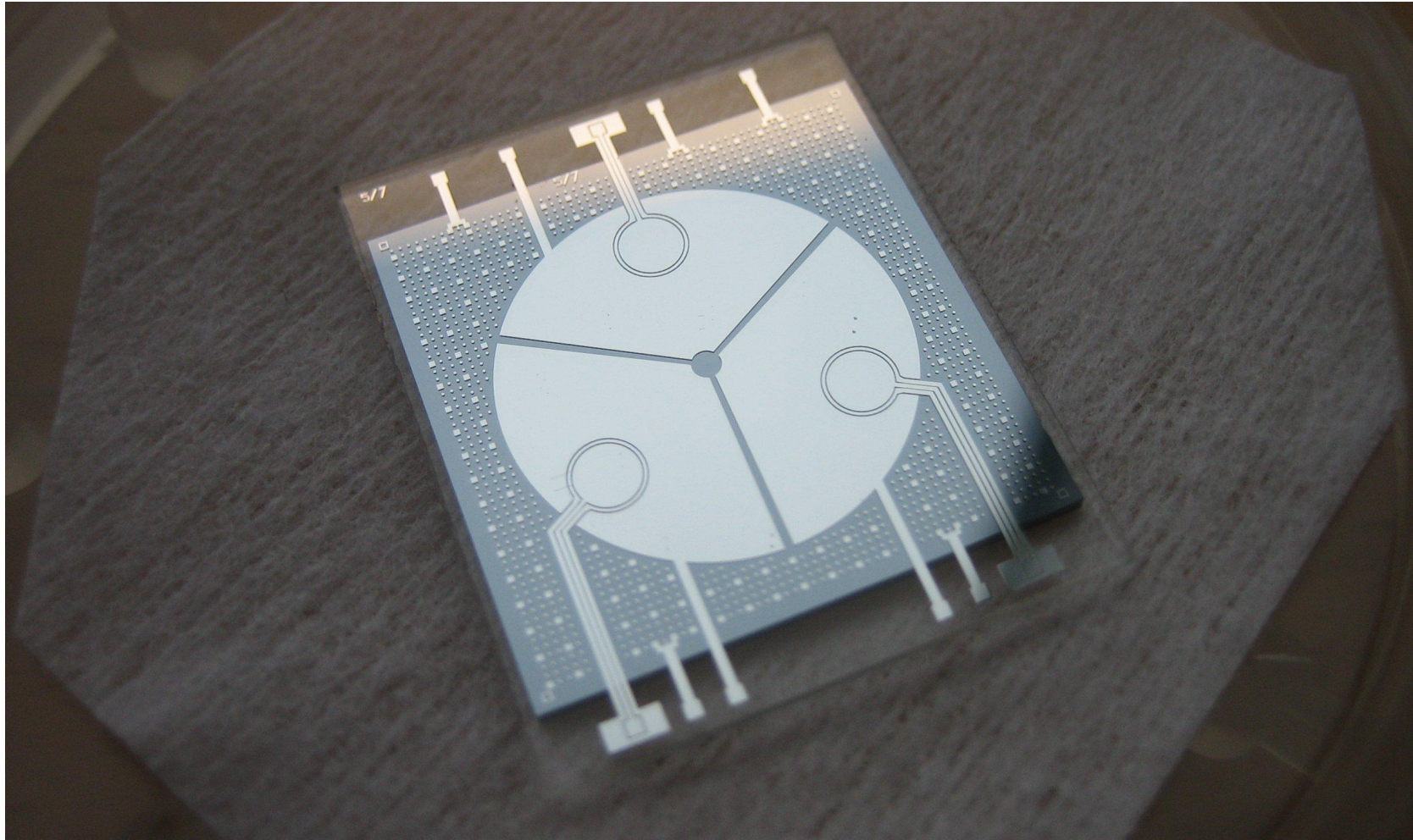


Vaisala Remote Road Surface State Sensor DSC111. Features remote surface state sensing with spectroscopic measuring principle, identifying the presence of water, ice, slush, snow or frost.

Ozone Monitoring Instrument (OMI) including VTT's detector module - the instrument is currently flying onboard NASA's EOS-AURA satellite creating high resolution ozone maps.

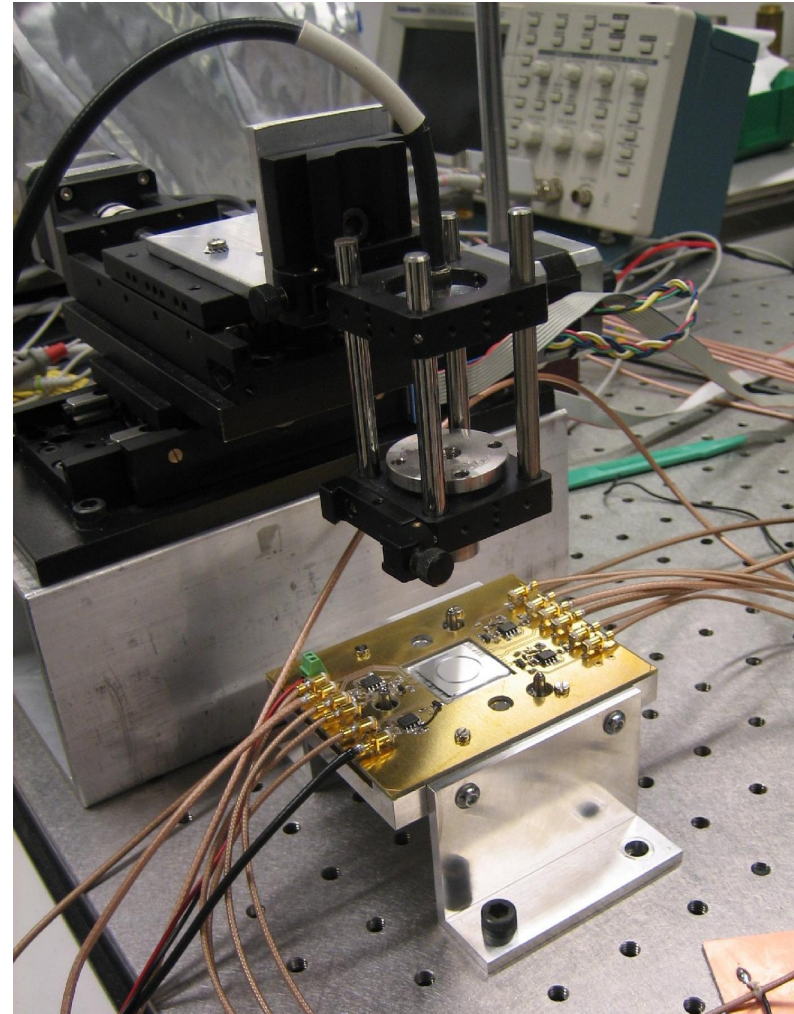


MEMS mirror component



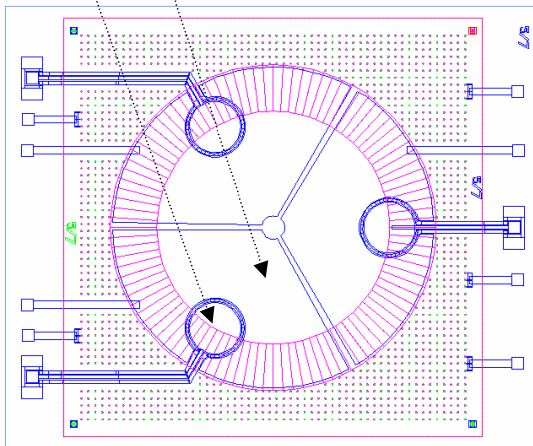
MEMS mirror component

- First MEMS mirror components of this type were manufactured in March 2007.
 - Air gap $\sim 50 \mu\text{m}$
 - Yield over 50%
- Control electronics for laboratory tests have been characterized
 - Electrostatic deflection
 - Capacitive position measurement
- Possibility to monitor mirror movement optically with white light interferometer.



MEMS mirror component

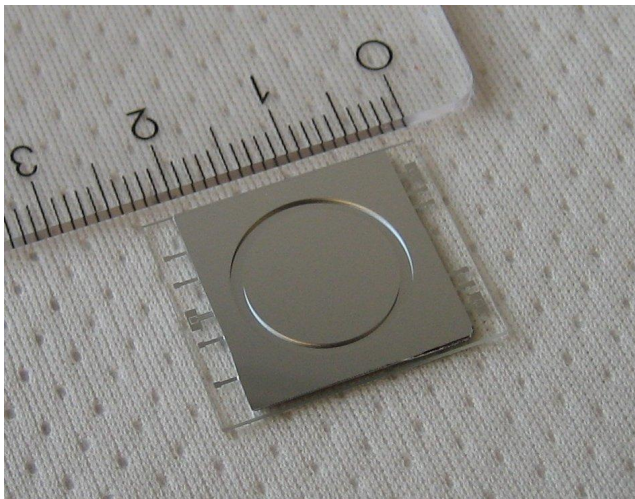
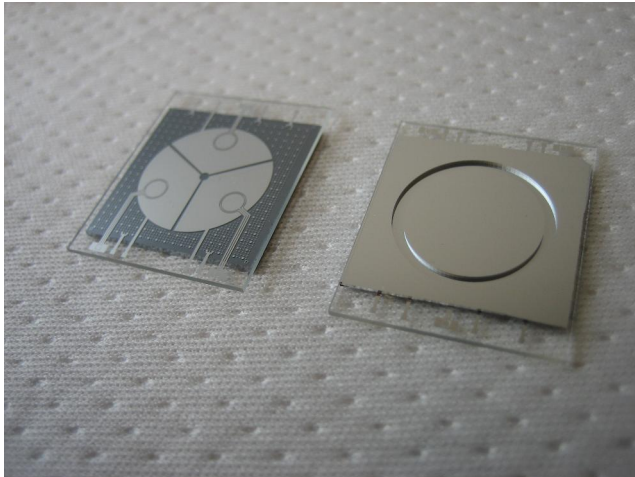
- Displacement of the mirror is caused by electrostatic force.
 - 3 electrodes on the glass substrate.
- Mirror movement is monitored with capacitive position measurement.
 - 3 electrodes on the glass substrate.



Electrostatic
force



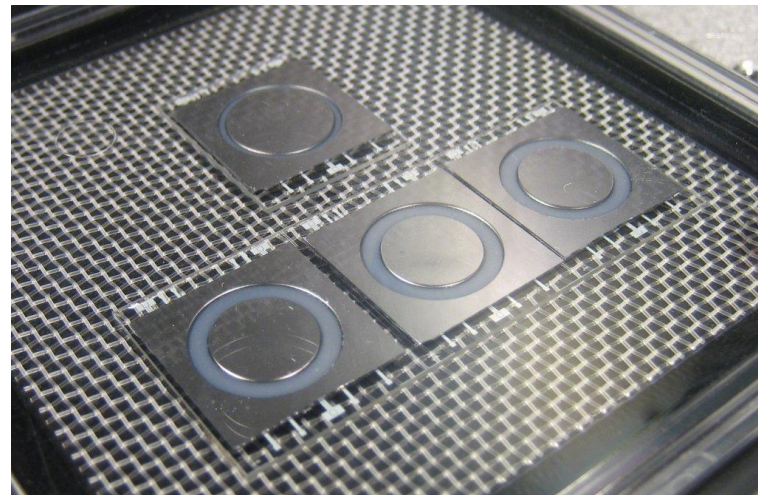
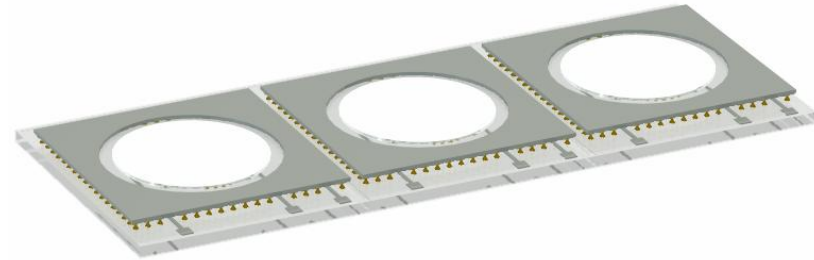
MEMS mirror component



- The air gap between glass substrate and metallized silicon mirror part is created using flip-chip bonding and SnPb-bumps
 - Parallelism of bonded chip and substrate is of the order of one micron.
 - Air gap can be adjusted possibly even more than 100 μm .
 - By varying spring geometry, spring constant can be tailored.

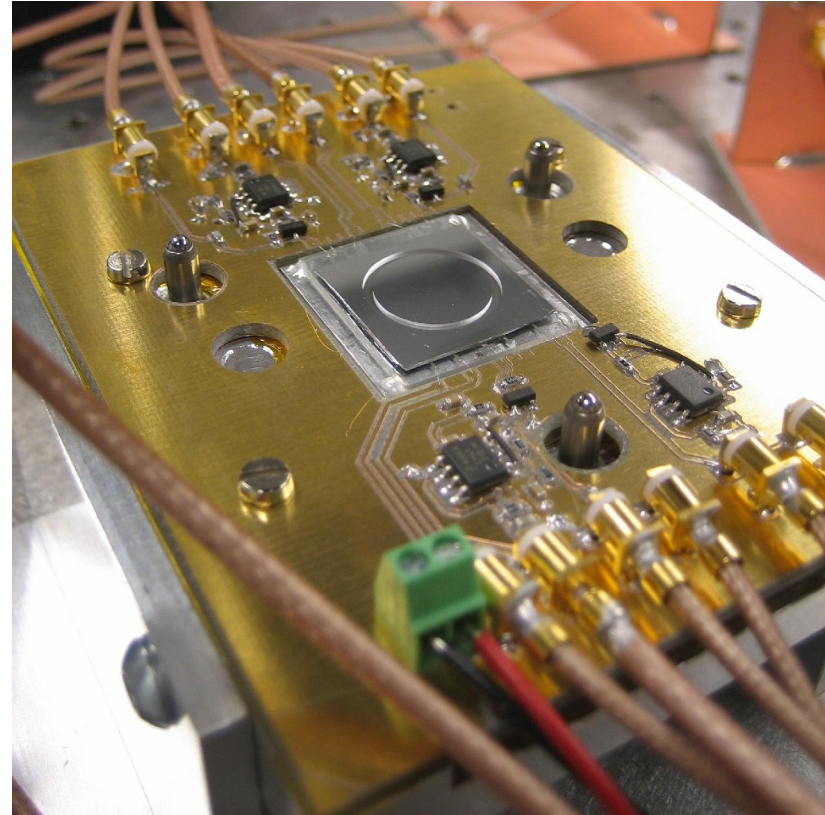
Alignment of multiple mirror on a single substrate

- Technique allows several silicon chips to be bonded on the same substrate.
- Positioning can be done at the mask level.
- Extremely good parallelism between independently controllable mirrors.
- Makes possible to use multiple reflections accurately.

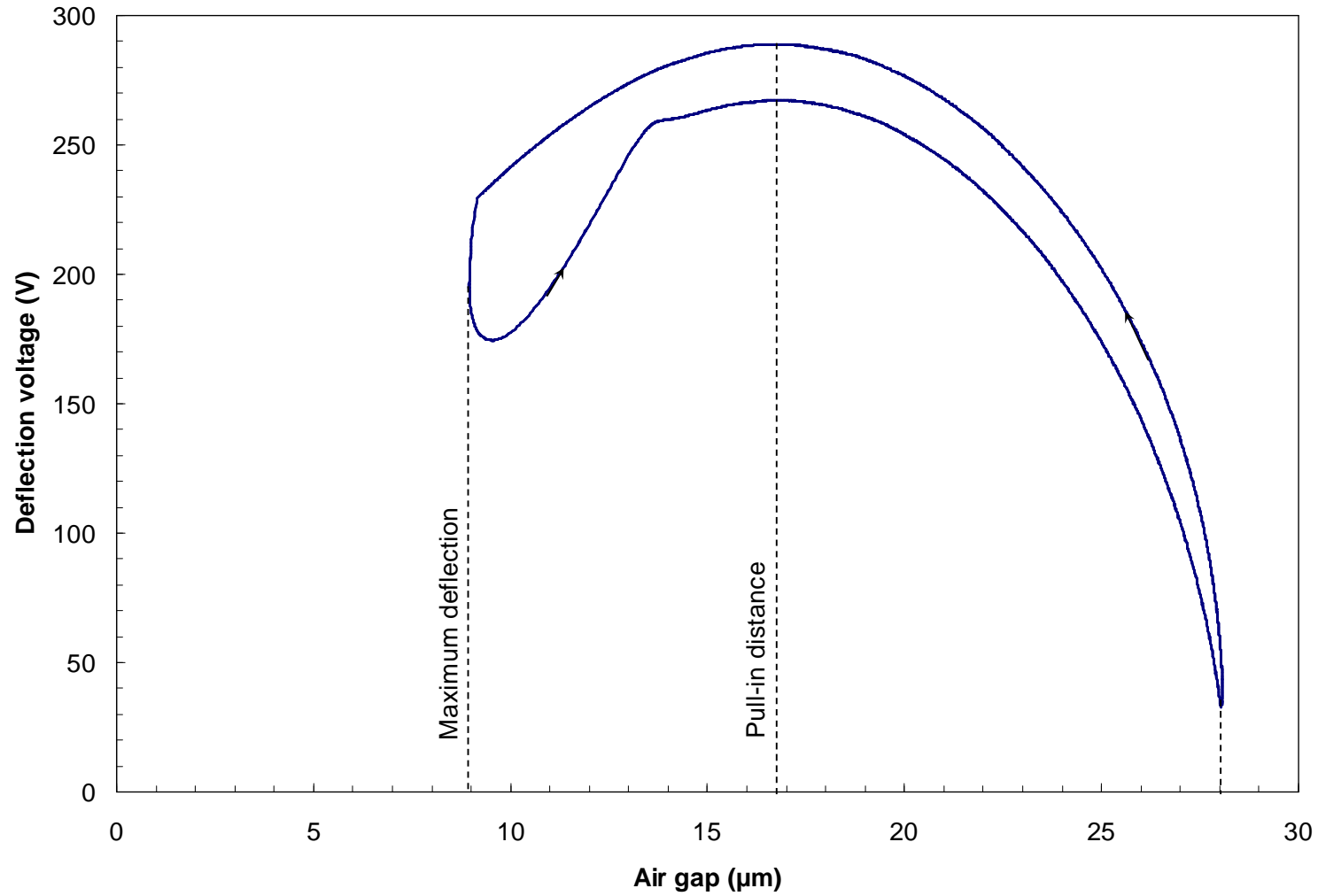


Electronics and mechanical performance

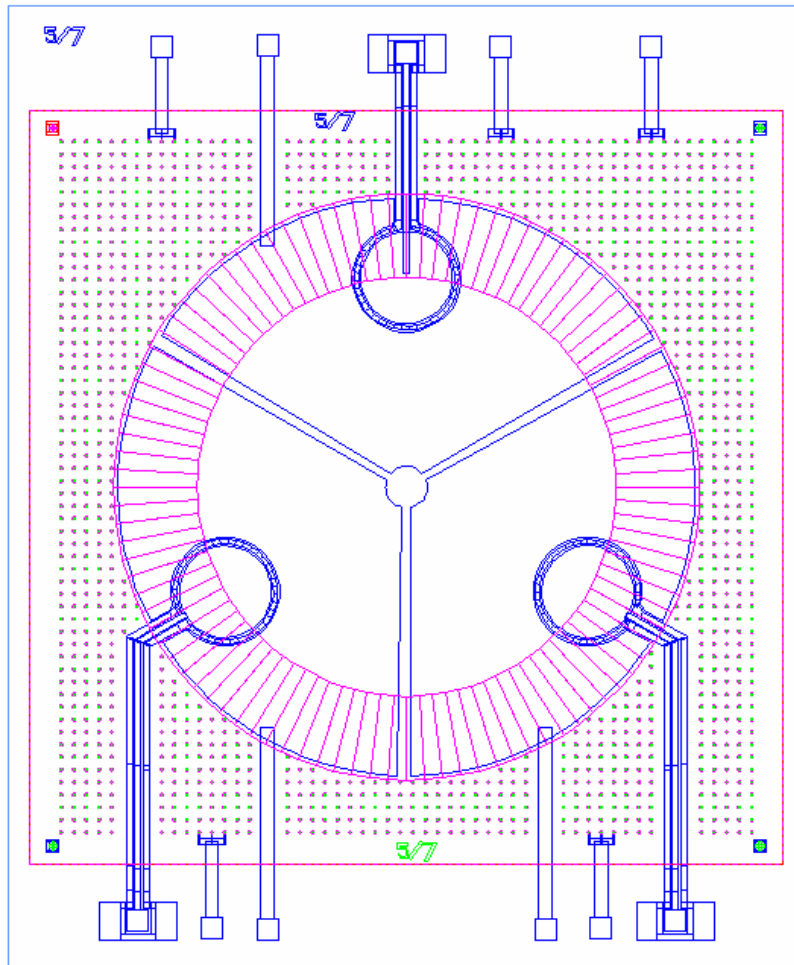
- First test electronics
 - mirror displacement is controlled with closed loop.
 - Position accuracy $< 1\text{nm}$.
- Currently the maximum velocity of the MEMS mirror is limited by the air damping.
 - Maximum frequency $\sim 60\text{ Hz}$ @ $\sim 10\text{ }\mu\text{m}$ displacement
- Pull-in distance has been exceeded in laboratory.
 - $2/3$ of the gap has been exploited.



Exceeding pull-in distance with closed loop control



First improvements



- Based on characterization experiences, first improvements have been implemented on the photolithographic masks.
 - Improved voltage breakdown limits
 - Better possibility to monitor mirror movements also optically
 - Improvement of ohmic contact to common silicon electrode
- Next improvements for the symmetry of the layer structure and layer thicknesses.

Mirror surface quality

Date: 04/17/2007

Time: 17:36:48

Surface Stats:

Ra: 580.52 nm

Rq: 684.27 nm

Rt: 3.16 μm

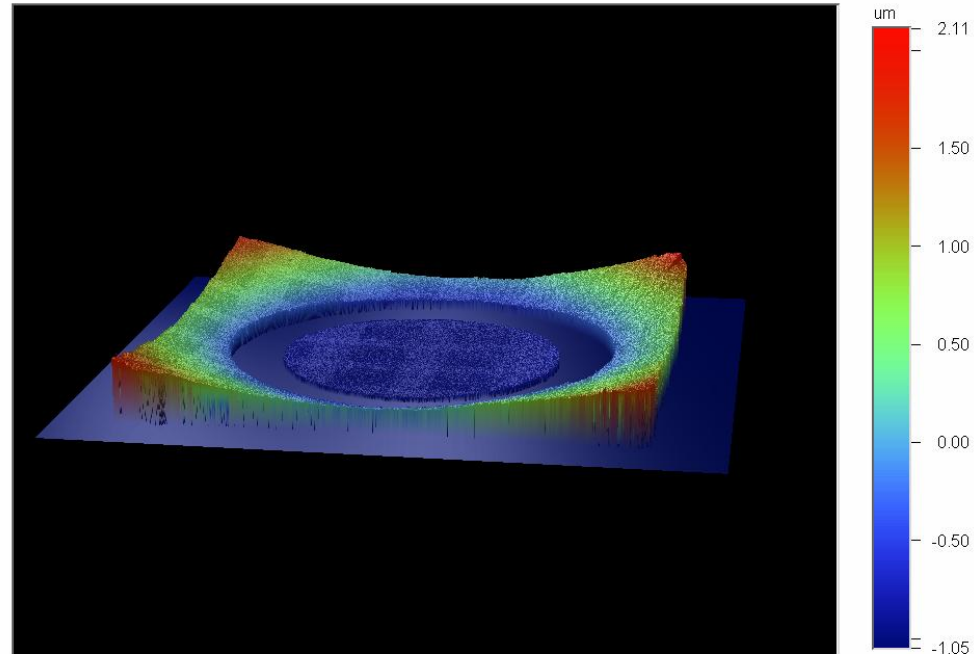
Measurement Info:

Magnification: 1.26

Measurement Mode: VSI

Sampling: 6.68 μm

Array Size: 3376 X 2701

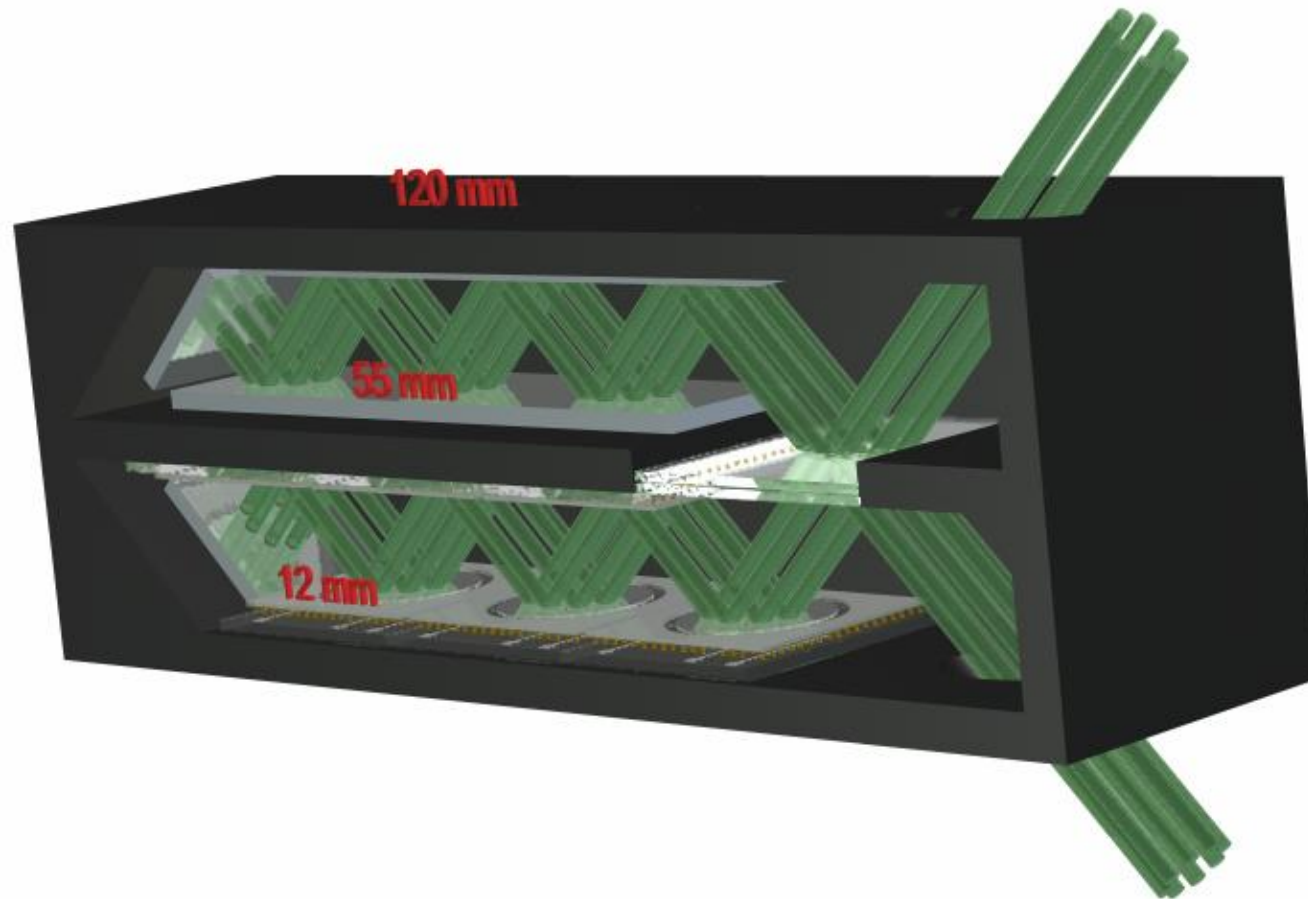


Title: Bondattu FTIR-3

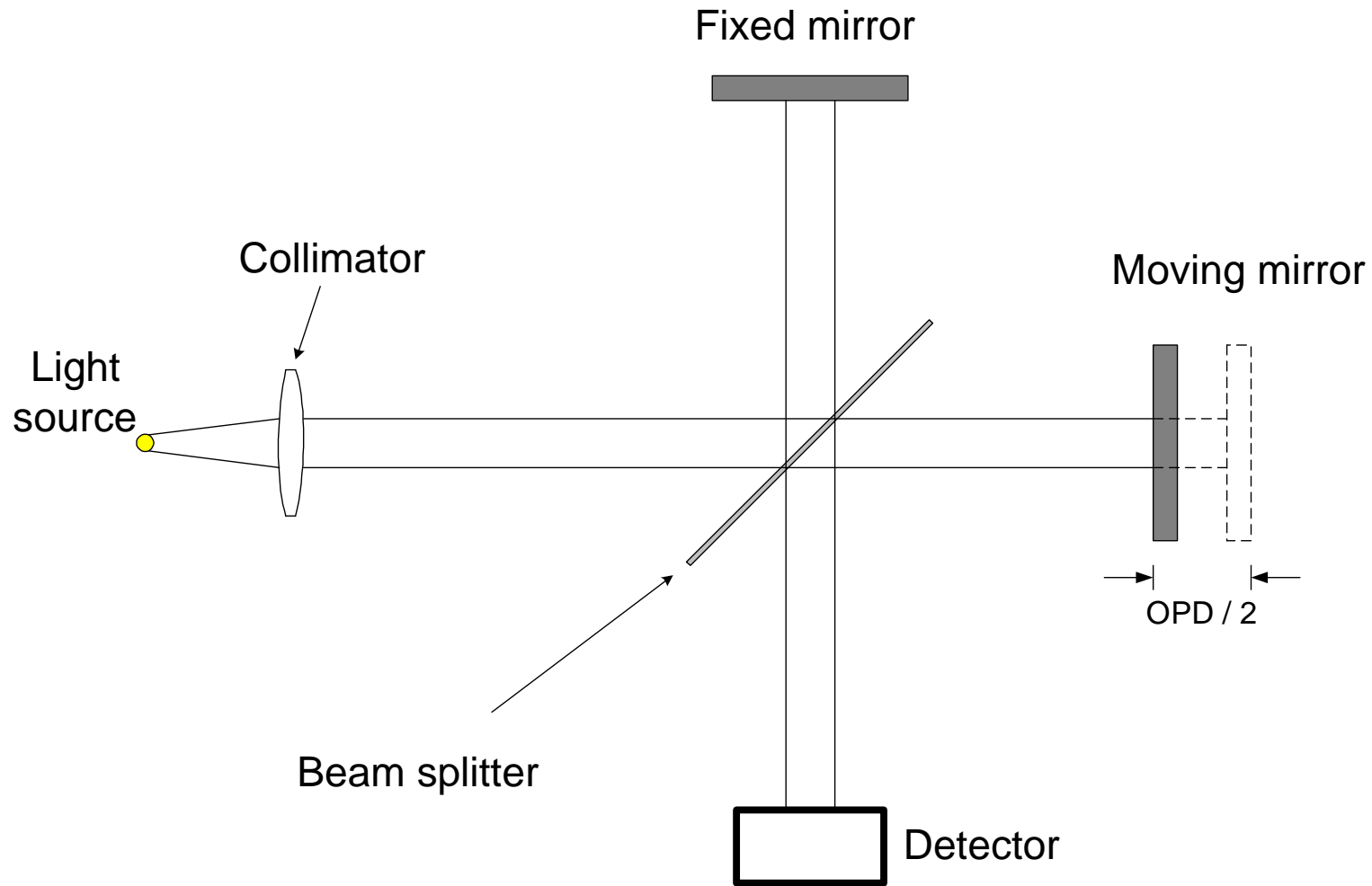
Note: 2.5X magn, 3X speed, 0.5X FOV

- Surface flatness of three MEMS mirrors was measured with profilometer.
- Mirror surfaces are saddle shaped
 - Curvature magnitude in range of 1 ... 200 nanometers
 - Probable reason lack of symmetry in layers structure

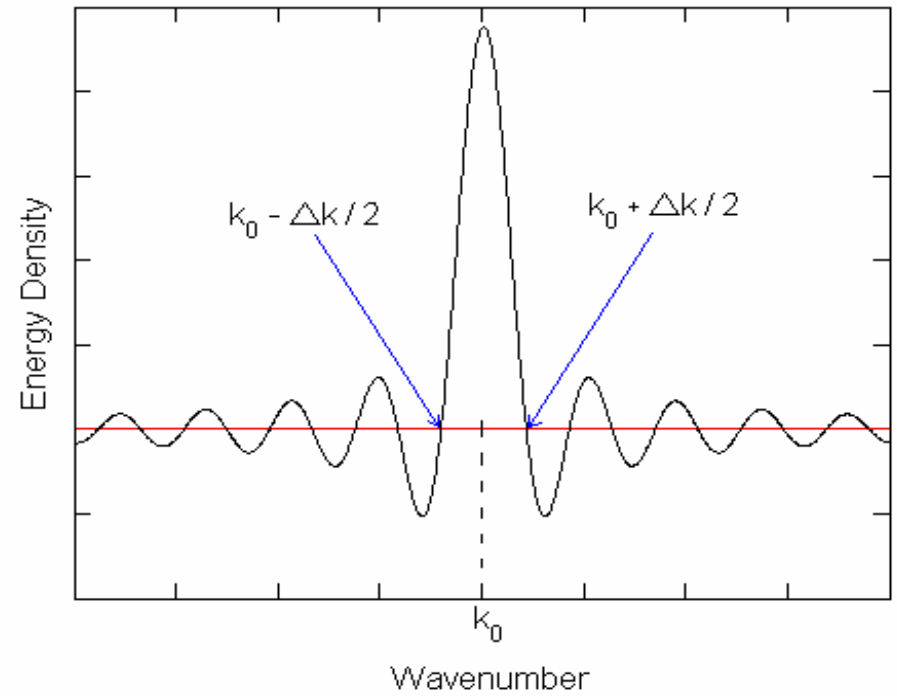
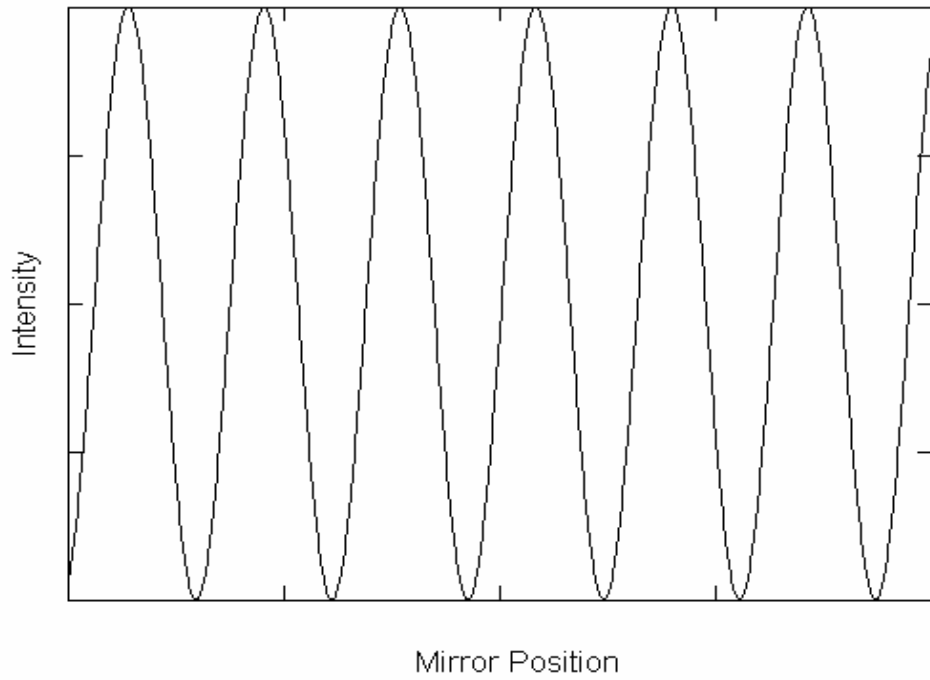
Laboratory tests and designed Fourier Transform Spectrometer



Michelson interferometer

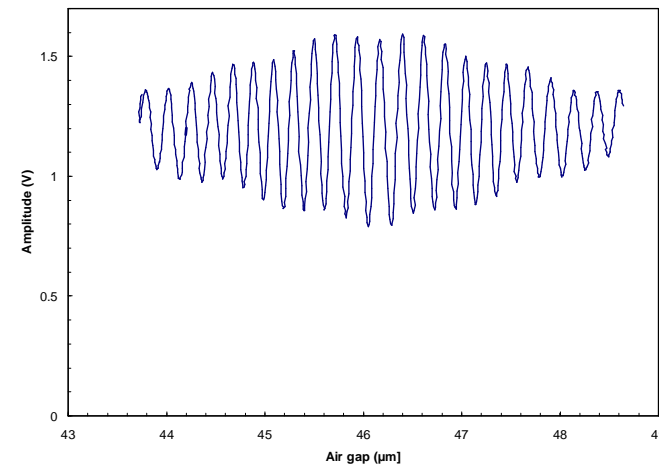
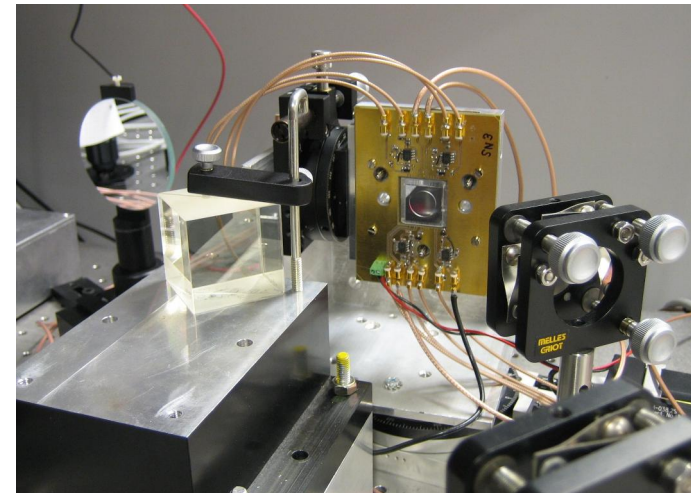


Monochromatic source



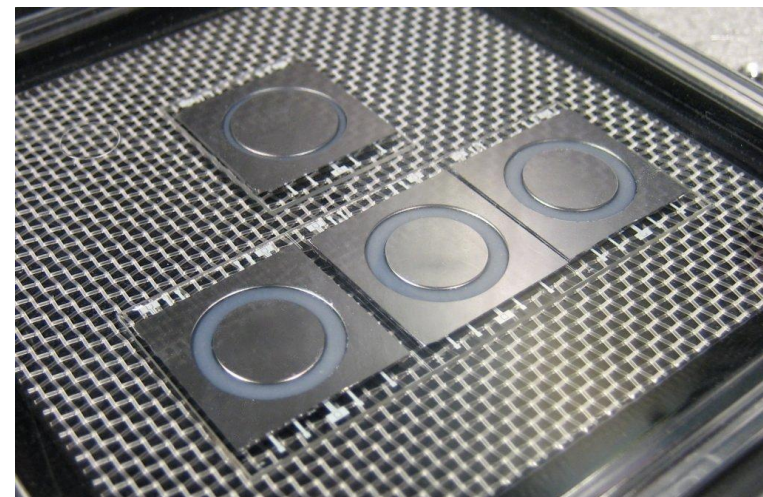
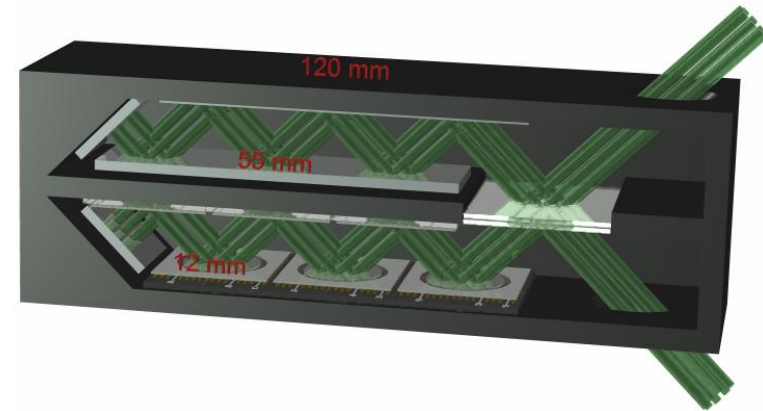
Laboratory test setup for MEMS mirrors

- Fourier transform spectrometer utilizing a MEMS mirror, with two reflections, has been constructed in laboratory environment.
- Preliminary test measurements with laser, diode and white light have been carried out.
- No adequate beam collimation.
- Difficult to use whole mirror diameter due to the surface flatness.



Miniaturized interferometers based on MEMS mirrors

- VTT has designed interferometer platforms that could utilize several precisely moving MEMS mirrors and multiple reflections.
- Chosen technology promises fast, rugged spectrometer platforms suitable for various online process measurements and other demanding environments.
 - chemical, biological, pharmaceutical,
 - industrial control measurements,
 - and space applications.
- Issues for the feasibility study
 - Wavelength reference
 - Geometry and packaging
 - Handling of vibrations and temperature gradients
- Key target specifications for hand-held Fourier spectrometer
 - optical path difference >1 mm
 - spectral resolution <3 nm @ 1500 nm
 - mirror position accuracy <1 nm



Conclusions

- VTT has developed accurately controllable MEMS mirror component with extraordinary large mirror surface.
- Mirror component could be used in harsh environments, such as space applications.
 - Fast and accurate position measurement
 - Closed loop-control

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